

**Effects of humidity on non-hermetically packaged III-V
structures and devices**

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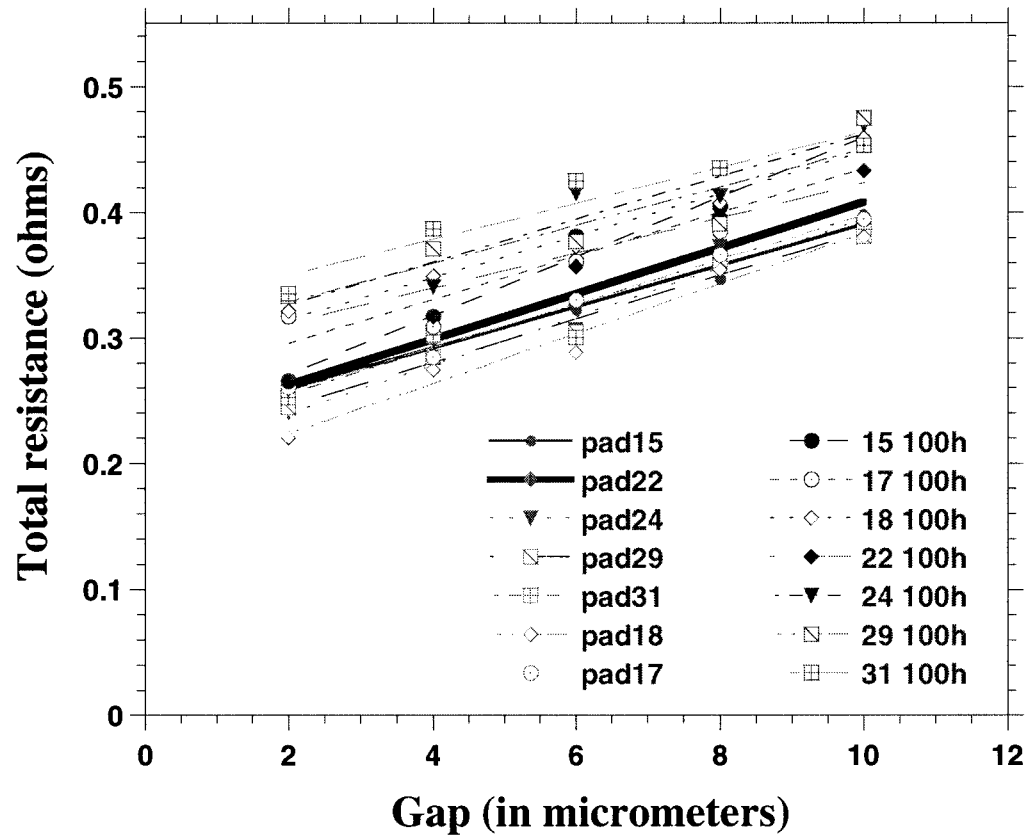
ABSTRACT

High humidity and temperature tests (known as 85/85 tests) were performed on various III-V devices and structures to determine environmental effects in non-hermetically packaged GaAs membrane mixer diodes. Results are shown for conventional recessed Au/Ge/Ni/Ag/Au ohmic contact test structures, thin films of AlGaAs and for anode-less and operational 2.5 Terahertz mixer diodes. Performance and morphological degradation were determined by using four point probe measurements (transmission line method) for ohmic contacts, by Scanning Electron Microscopy examination and by measuring the DC voltage current (I-V) characteristics in the membrane diodes. The 85/85 humidity test caused a slight degradation in the contact resistance of the ohmic contact test structures and an increase in the scatter in measurements between similar test contact structures. Blistering in various regions of the GaAs membrane diodes and complete consumption of epitaxial AlGaAs test films were also found. However, the I-V characteristics of the 2.5 THz membrane-diode mixers did not degrade after 500 hours at 85°C and 85% relative humidity.

Background/Motivation

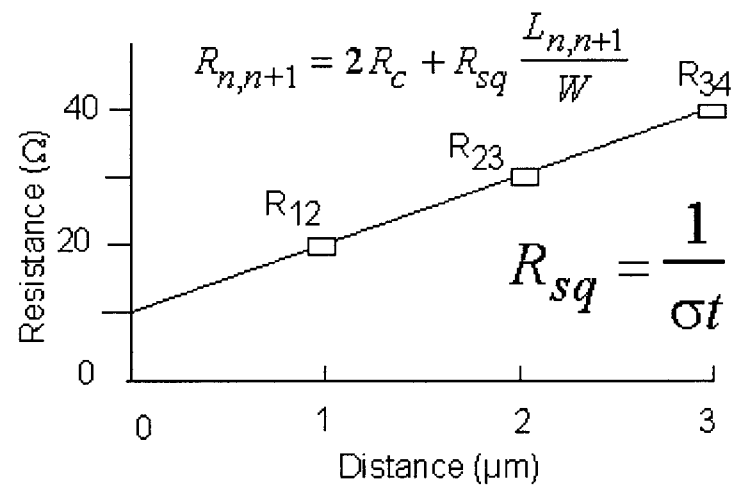
Some of the far infrared sensing applications for III-V devices are incompatible with hermetic enclosure of the sensing device due to the unavailability of non-absorbing window materials. The effects of humidity on semiconductor devices have shown detrimental effects in the past, from failures due to large increases in threshold current in InP-based lasers [1] to mechanical stresses due to polymeric layers volume expansion in micro-mechanical devices [2]. Humidity in Ag based metallization in microelectronic interconnects has caused metal corrosion and dendrites due to migration [3].

This study was undertaken with the 2.5 THz GaAs monolithic membrane-diode mixers (fabricated at the Jet Propulsion Laboratory) to be used on the Earth Observing System Microwave Limb Sounder instrument [4,5]. These devices will be used to measure and differentiate the emission from O_2 at 2502 GHz and OH at 2510 and 2514 GHz (119.820, 119.438 and 119.248 microns respectively). The tests were done to assess any possible effects from moisture during the pre-launch time period.

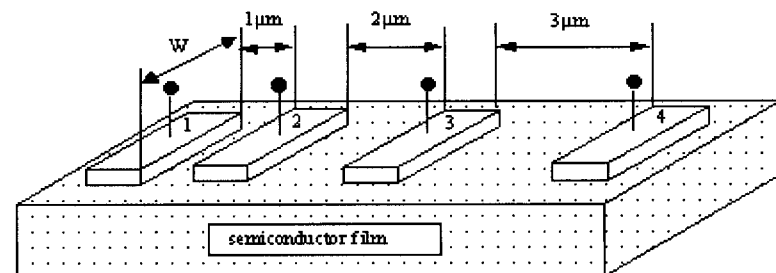


Degradation in contact resistance after 100 hours in an 85% humidity environment and 85 degrees. The test structures consisted of a pad of equal area with varying separation between metallization in GaAs ohmic contacts. This data is relevant to both the 640 Ghz and 2.5 Thz mixer diodes. The contact resistance for these structures degraded from an average of $5.16 \times 10^{-6} \Omega \text{ cm}^2$ to an average of $6.44 \times 10^{-6} \Omega \text{ cm}^2$, roughly 20%. Second set of data shows more scatter in values but still shows a statistically significant degradation.

Resistance versus distance



Transmission Line Model

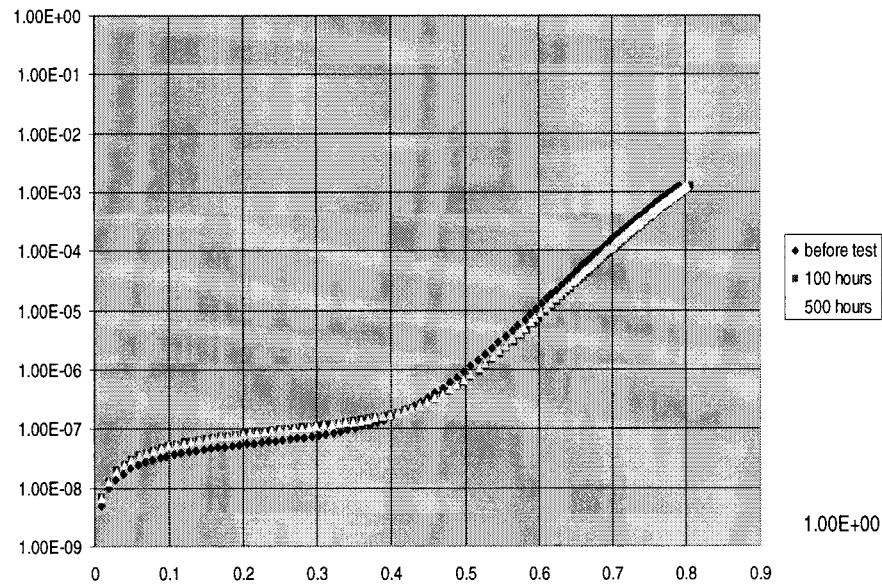


Device		Pre-testing IV data	After 100 hours at 85°C and 85% relative humidity	After 500 hours 85°C and 85% relative humidity
Ret 2,5 R1c3 lh test type E	I _s η R _s	6.7 x 10 ⁻¹² (Amps) 1.61 25.1 (ohms)	1.5 x 10 ⁻¹² 1.47 18.5	2.2 x 10 ⁻¹² 1.49 19.1
Ret 2,5 R1c3 rh test type E	I _s η R _s			5.4 x 10 ⁻¹² 1.47 14.0
Ret 5,3 R3c2 type B	I _s η R _s	2.7 x 10 ⁻¹² 1.54 8.50	1.3 x 10 ⁻¹² 1.51 8.84	1.6 x 10 ⁻¹² 1.52 9.97
Ret 5,3 R3c2 lh test type B	I _s η R _s	2.9 x 10 ⁻¹² 1.56 18.2	3.1 x 10 ⁻¹² 1.52 17.7	2.7 x 10 ⁻¹² 1.51 17.4
Ret 5,3 r4c4 type F	I _s η R _s	2.5 x 10 ⁻¹² 1.51 10.9	1.1 x 10 ⁻¹² 1.49 9.60	1.3 x 10 ⁻¹² 1.49 10.1
Ret 5,3 r4c4 lh test type F	I _s η R _s	NA	3.6 x 10 ⁻¹² 1.54 24.9	4.9 x 10 ⁻¹² 1.54 29.9
Ret 5,4 R3c1 type B	I _s η R _s	7.3 x 10 ⁻¹² 1.61 13.3	6.0 x 10 ⁻¹² 1.55 11.6	2.3 x 10 ⁻¹² 1.48 10.4
Ret 5,4	I _s			2.1 x 10 ⁻¹²

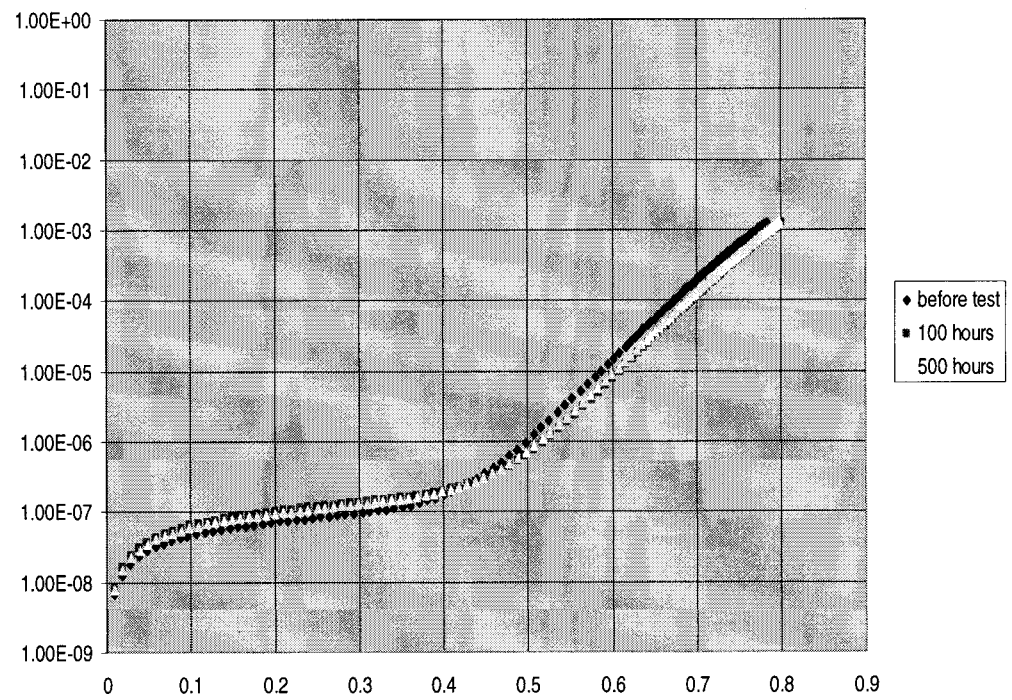
Table 1. Changes in contact resistance (in ohms) after 100, 500 and 1000 hours in 85/85 humidity test. Test pads distributed among 4 GaAs wafer pieces (1 and 3), (4, 5 and 6), (10, 12, 13 and 14) and (15, 16, 17, 18, 19, 22, 24, 26, 29, 30 and 31). Piece containing 10, 12, 13 and 14 showed some very high contact resistance from some of the pads (not used in test) and other anomalous behavior.

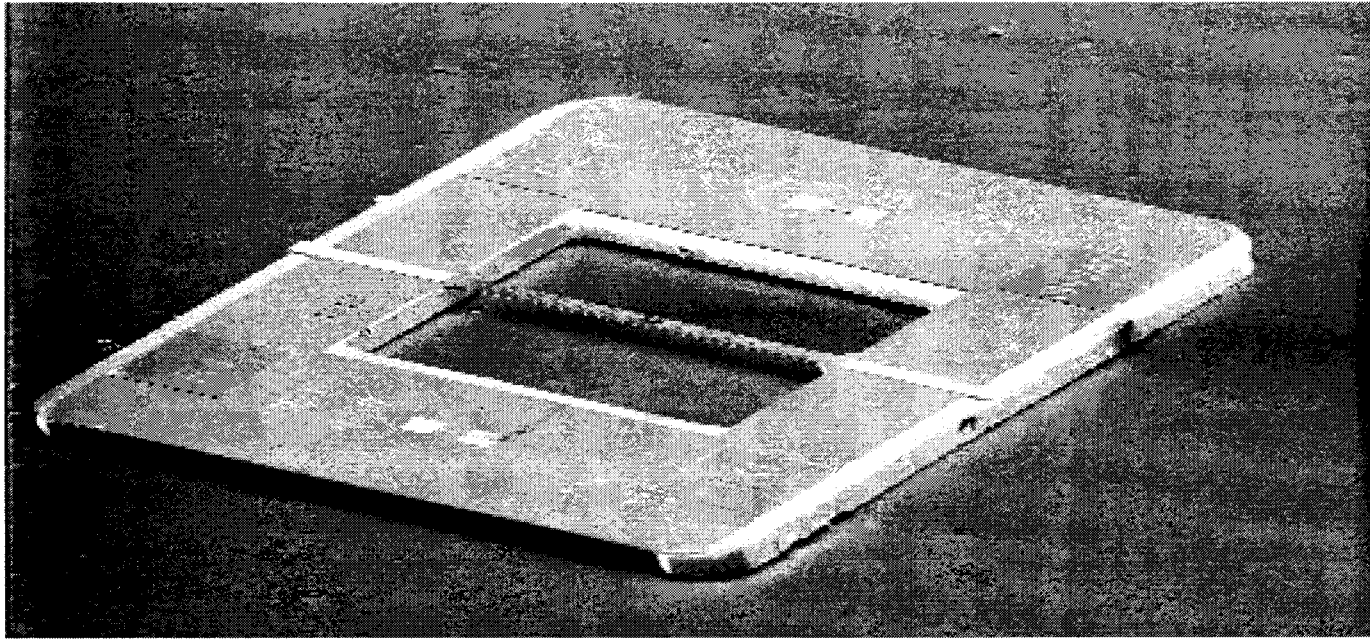
Pad#	initial Rs	after 100h	% dif	after 500h	% dif	after 1000h	% dif
1.0000	6.4000e-06	7.4050e-06	15.703	8.3000e-06	29.687	6.3900e-06	-0.15626
3.0000	8.1350e-06	9.6750e-06	18.931	7.6500e-06	-5.9619	6.2200e-06	-23.540
4.0000	6.4218e-06	8.7135e-06	35.687	4.8800e-06	-24.008	4.0100e-06	-37.556
5.0000	6.4750e-06	8.1075e-06	25.212	5.6200e-06	-13.205	8.8700e-06	36.988
6.0000	6.5250e-06	8.0000e-06	22.605	6.0200e-06	-7.7395	8.1030e-06	24.184
10.000	6.4425e-06	5.5400e-06	-14.009	5.8300e-06	-9.5072	3.3400e-07	-94.816
12.000	7.2400e-06	8.2500e-06	13.950	7.1600e-06	-1.1050	7.5000e-06	3.5912
13.000	7.2750e-06	7.5550e-06	3.8488	6.5700e-06	-9.6907	6.8125e-06	-6.3574
14.000	7.4000e-06	8.2000e-06	10.811	6.5550e-06	-11.419	6.7500e-06	-8.7838
15.000	5.6500e-06	5.6000e-06	-0.8849	7.0000e-06	23.894	0.0000	-100.00
16.000	6.6250e-06	7.8850e-06	19.019	8.8500e-06	33.585	1.0166e-05	53.449
17.000	5.5500e-06	6.5275e-06	17.613	7.1300e-06	28.468	8.6500e-06	55.856
18.000	4.5900e-06	7.0500e-06	53.595	6.5100e-06	41.830	7.7400e-06	68.627
22.000	5.6500e-06	7.1000e-06	25.664	7.5150e-06	33.009	8.4000e-06	48.673
24.000	5.0300e-06	7.3250e-06	45.626	6.3800e-06	26.839	6.8200e-06	35.586
29.000	5.2605e-06	7.4650e-06	41.907	6.4700e-06	22.992	7.0800e-06	34.588
31.000	5.4910e-06	8.0540e-06	46.676	6.2550e-06	13.914	7.5600e-06	37.680
33.000	5.3350e-06	6.1393e-06	15.075	5.7900e-06	8.5286	6.4660e-06	21.200
26.000	5.3500e-06	6.4357e-06	20.294	6.1200e-06	14.393	3.6400e-06	-31.963
19.000	4.7925e-06	6.7350e-06	40.532	5.4200e-06	13.093	2.8960e-06	-39.572
Means	6.08e-6	7.39e-6	22.9%	6.6e-6	10.4%	6.22e-6	3.9%
St. Dev	9.1e-7	1.04e-6	17.1	9.72e-7	19.4	2.7e-6	47.4

85C 85% humidity test
OH-III 027 ret(5,3) r3c2 type B

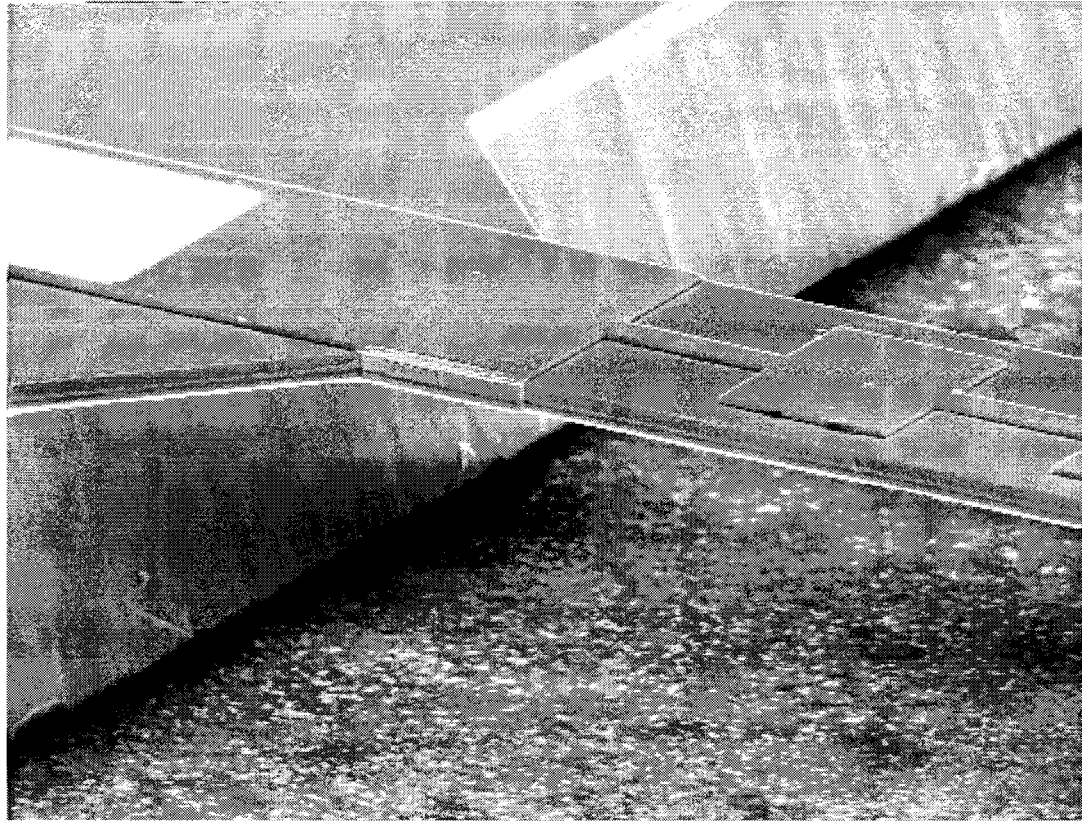


85C 85% humidity test
OH-III 027 ret(5,3) r4c4 type F

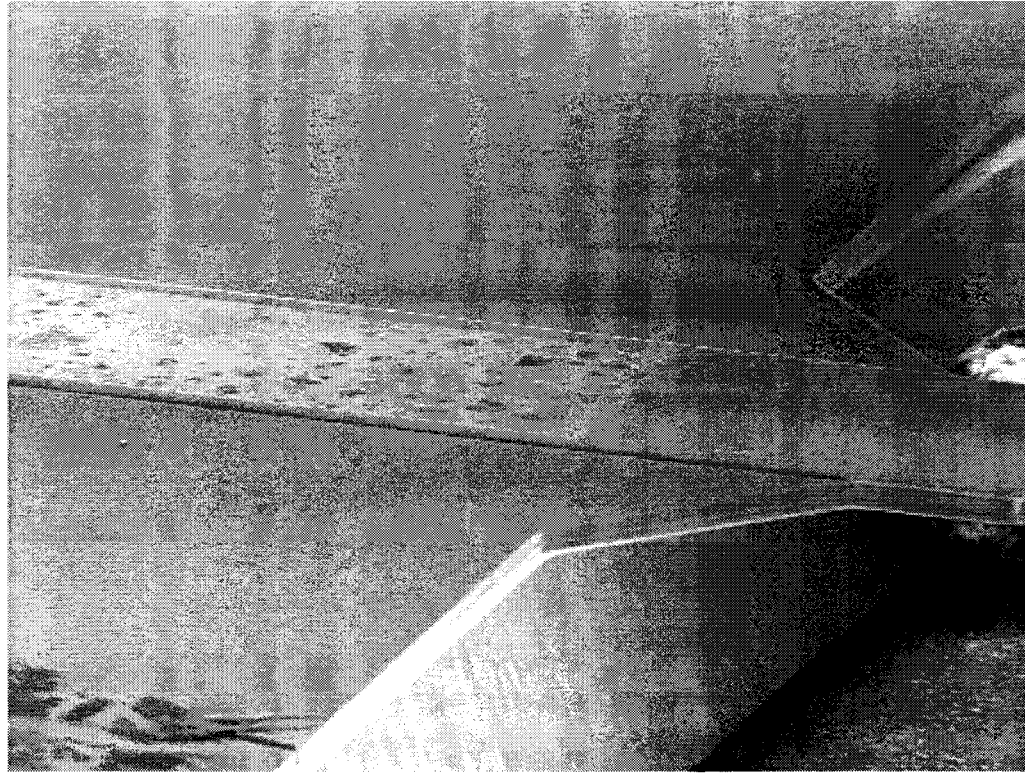




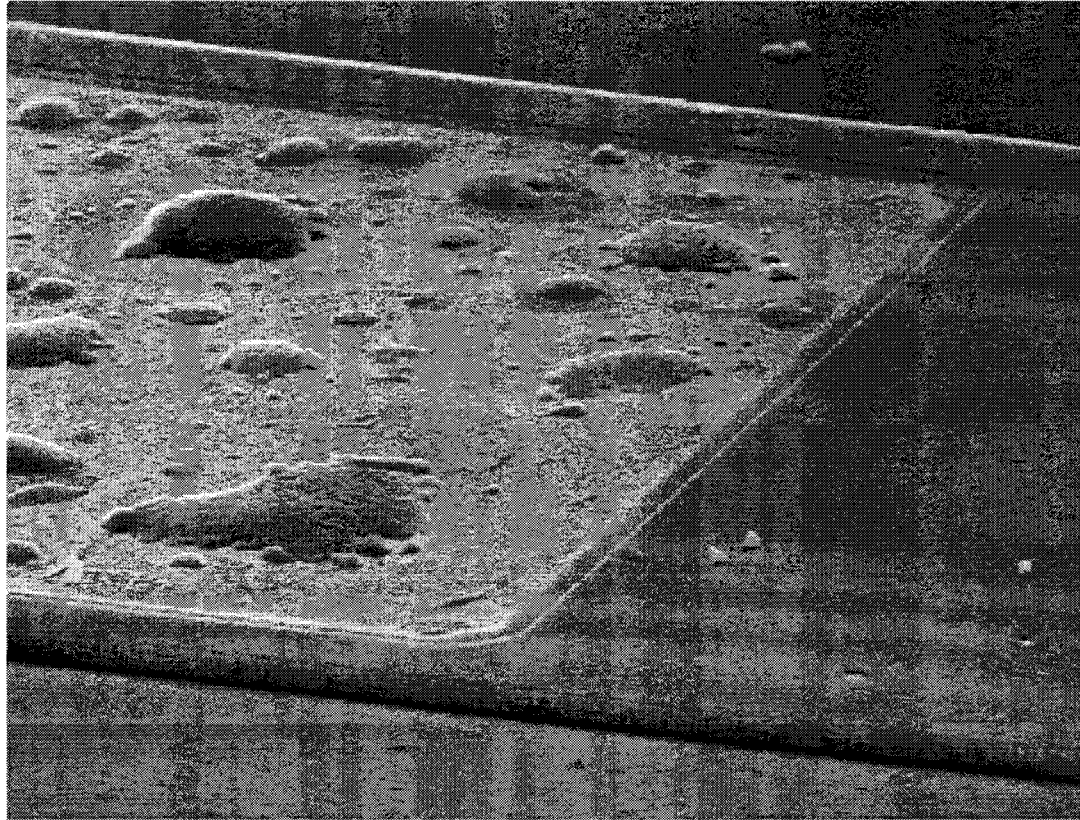
Scanning electron micrograph of
2.5 THz GaAs membrane diodes and
frame prior to humidity testing.
Membranes are 3 micrometer thick.



Enlarged view of membrane
without humidity testing.



“Blistering” in unprotected metallization in GaAs mixer diodes after 1000 hours at 85 C and 85 % RH.



Enlarged view of blistered area.

Conclusions

- **AlGaAs is unsuitable for nonhermetic device applications even with a 30 nm GaAs cap. The effectiveness of other standard passivating films still remains to be investigated.**
- **2.5 THz GaAs membrane mixer diodes (with unpassivated membrane backs) do not show degradation in their DC I-V characteristics after 500 hours of 85/85 testing.**
- **Process residues can cause morphological changes (“blistering”) in exposed areas of GaAs devices subject to humidity testing.**
- **Unpassivated standard recessed Au/Ge/Ni/Ag/Au ohmic contacts on GaAs suffer a slight degradation in contact resistance (R_s). Values for R_s from different test pads show much greater variance after the 85/85 tests. Identifying the cause for this variance will require more detailed structural characterization like transmission electron microscopy or scanning probe microscopy analysis.**

References

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